

Processed Substrate Surface for Epoxy Deposition and Method thereof

ABSTRACT

The present invention provides a method for treating a substrate having a surface of deposition, the method comprises providing a hydrophilic coating over the surface of the substrate; and providing a hydrophobic coating on an area of deposition, wherein the area is a dedicated area over the surface of deposition. The dedicated area attributes a contrasting liquid attracting-repelling properties against a remaining area outside the area of deposition. The substrate treated with the above method is also provided.

FIG. 5